

511.40998X00

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants: N. KOYAMA et al  
Application No.: 10/018,188  
Filed: December 18, 2001  
For: CMP ABRASIVE, METHOD FOR POLISHING SUBSTRATE  
AND METHOD FOR MANUFACTURING SEMICONDUCTOR  
DEVICE USING THE SAME, AND ADDITIVE FOR COMP  
ABRASIVE  
Art Unit: 3724  
Examiner: T. Eley

**PETITION FOR EXTENSION OF TIME**

Commissioner For Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

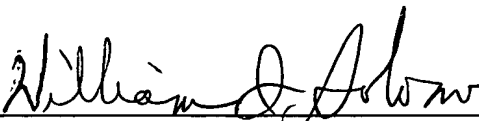
March 22, 2005

Sir:

In the matter of the above-identified application, Applicants hereby respectfully petition for an extension of time to permit filing a response within the third month subsequent to expiration of the shortened statutory period set in the outstanding Office Action, mailed November 22, 2004. A credit card payment form in the amount of \$1,020.00 to cover the required fee for the requested extension of time is attached hereto.

It is respectfully requested that any shortage in the fee be charged to the deposit account of Antonelli, Terry, Stout & Kraus, LLP, Account No. 01-2135 (511.40998X00) and any excess fees credited to that account.

Respectfully submitted,  
ANTONELLI, TERRY, STOUT & KRAUS, LLP

By   
William I. Solomon  
Reg. No. 28,565

WIS/dlt

03/23/2005 JADD01 00000093 10018188

1300 North Seventeenth Street, Suite 1800  
Arlington, Virginia 22209  
Telephone: (703) 312-6600  
Facsimile: (703) 312-6663

1020.00 OP